



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Tadahiro OHMI et al.

Title:

PLASMA PROCESSING APPARATUS

Appl. No.:

10/584,137

Filing Date:

8/1/06

Examiner:

Keath T. Chen

Art Unit:

1792

Confirmation No.:

4094

AMENDMENT AND REPLY UNDER 37 CFR 1.116

Mail Stop **BOX AF**Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This communication is responsive to the Final Office Action dated November 5, 2008, concerning the above-referenced patent application.

Applicants have submitted herewith a petition and fee for a three-month extension of time, to make this response timely.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this document.

Remarks/Arguments begin on page 5 of this document.

Please amend the application as follows:

05/04/2009 MAHMED1 00000014 10584137

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